

Synthesis and characterization of spinel $\text{ZnAl}_2\text{O}_4:\text{SnO}_2$ thin films for optoelectronic applications

Abdelmalek Kharroubi^{*1}, Hadj Benhebal^{#2}, Bedhief Benrabah¹, Touati Mohamed¹, Hireche
Khaoula¹, Senni Amel¹

¹Laboratory of Physical Engineering Faculty of Mater Sciences, University of Tiaret, Algeria

²Department of Chemical, Faculty of Mater Sciences, University of Tiaret, Algeria

^{*}abdelmalek.kharroubi@univ-tiaret.dz

Abstract— ZnAl_2O_4 and $\text{ZnAl}_2\text{O}_4:\text{SnO}_2$ thin films with (3%, 6%)wt SnO_2 are deposited by the dip-coating technique on glass substrates and silicon substrates. Morphologic, optical and electrical properties of synthesized materials were investigated by atomic force microscopy (AFM). Fourier transform infrared spectroscopy, the ultra visible spectroscopy and complex impedance spectroscopy. The AFM images analysis revealed uniform surface and the effect of doping on the roughness of the layers has also been highlighted, we tracked the evolution of the surface roughness of the films as a function of the tin oxide content. The infrared transmission spectra obtained for different tin dioxide doping levels show a band observed at 655 cm^{-1} confirm the formation of the normal spinel structure, ZnAl_2O_4 . The UV-Visible spectra show a high transmittance in the visible light range ($T \sim 98\%$ for pure ZnAl_2O_4 and between 85% and 86% for all doped samples). The optical gap varies from 3.80 eV (for the undoped) to 3.68 eV for the sample doped with 6% SnO_2 . Complex impedance spectroscopy indicates that the effect of grain boundaries is dominant in the conduction mechanism. It is also observed that the equivalent circuit of undoped and SnO_2 -doped ZnAl_2O_4 films is a parallel RC circuit.

Keywords-Sol-gel, ZnAl_2O_4 , SnO_2 -doped, Thin films.

I. INTRODUCTION :

Metal oxides in thin films in general and ZnAl_2O_4 films in particular have potential applications in many fields, essentially when one simulates ousley needs good transparency in the visible and good electrical conductivity [1-3]. Zinc aluminate (ZnAl_2O_4) whose natural mineral called gahnite is a spinel oxide with cubic structure (space group Fd-3m) [1-2]. It has several advantages, such as high chemical and thermal stability, good catalytic activity, low-temperature sinter ability, and mechanical strength. In addition, it is classified as a transparent wide-bandgap semiconductor with estimated gap energy of 3.8 eV. Due to its characteristics, ZnAl_2O_4 is important in many technological applications such as catalysis, ceramics, aerospace, dielectrics, electronics, and optoelectronic devices [3-4]. It has been reported that the addition of metallic impurities, in the form of atoms or oxides to ZnAl_2O_4 adjusts both the crystallite size and the bandgap, resulting in an improvement in many properties and consequently offering greater application potential [5-7]. In this work, sol-gel process was chosen to produce the ZnAl_2O_4 films. It makes it possible to obtain a material of high purity having good homogeneity compared to other conventional production methods such as chemical vapor deposition, pyrolysis or spraying. X-ray powder diffractograms of pure Gahnite.

II. EXPERIMENTAL

A. Samples synthesis

Zinc nitrate hexahydrate $\text{Zn}(\text{NO}_3)_2 \cdot 4\text{H}_2\text{O}$, Aluminium nitrate $\text{Al}(\text{NO}_3)_3 \cdot 9\text{H}_2\text{O}$, ethanol ($\text{C}_2\text{H}_5\text{OH}$), oxalic acid $\text{C}_2\text{H}_2\text{O}_4$ were used to prepare pure and SnO_2 -doped ZnAl_2O_4 thin films prepared by sol-gel method and deposited on properly cleaned Pyrex substrates ($75 \times 25 \times 1\text{ mm}^3$) using a dip-coating with a withdrawal speed of 50 mm/min. The formed films pass through the drying step in order to evaporate the solvent, finishing all that with a heat-treatment when the films were annealed in muffle furnace at 500°C for 15 min.

B. Samples characterization

The Morphology characterization of the film was analysed using a JEOL JSPM-5200.The optical properties were determined by optical transmittance measurements of the films using UV-1650 Shimadzu spectrophotometer in the wavelength range from 300 to 900 nm. FTIR spectra of the samples were recorded using a Shimadzu 8400 Spectrometer in the wave number range from 400 cm⁻¹ to 4000 cm⁻¹. The electrical characteristics were highlighted by impedance measurements performed using an Agilent 4284A LCR meter operating in the frequency range 75 kHz to 20 MHz with oscillation amplitude of 1 V.

III. SAMPLES CHARACTERIZATION

A. AFM analysis

Figure 1 shows 5 µm × 5 µm AFM images obtained for the pure and SnO₂ doped ZnAl₂O₄ films deposited onto glass substrates. Although each film exhibits a homogeneous distribution of grains, there is a visible change in the morphology of the films when they were doped tin oxyde. This is due to the coalescence of grains resulting at the effect of SnO₂ on the ZnAl₂O₄ matrix [8-10].

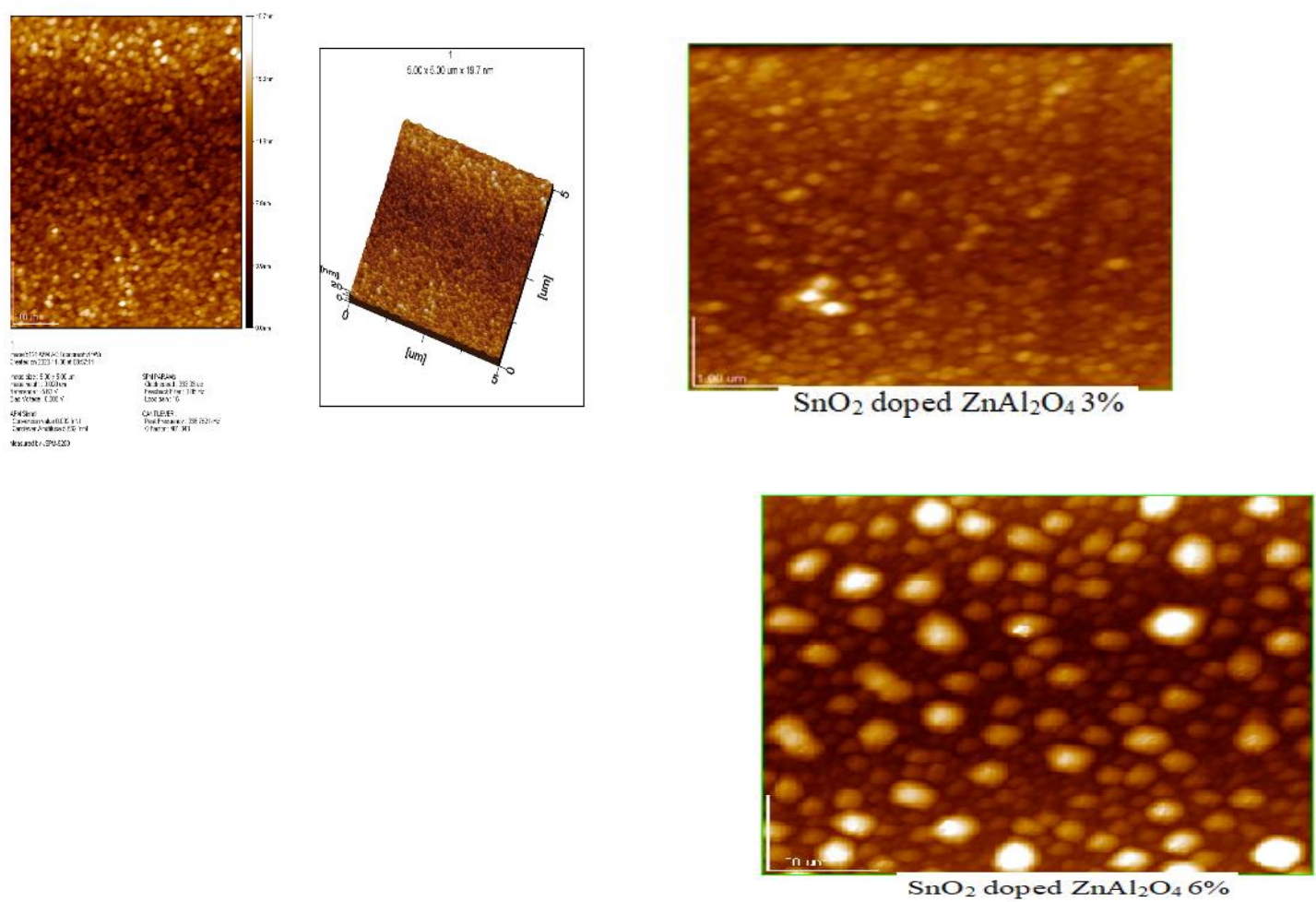


Fig.3 AFM images of pure SnO2 doped ZnAl2O4 thin film

B. FTIR Analysis

FTIR spectra were measured in the wavenumber region 400-4000 cm^{-1} . The band recorded at 3599 cm^{-1} can be attributed to the stretching vibration of H_2O molecules [11]. The small peak observed at 1444 cm^{-1} can be attributed to Al-O stretching vibrations [12].

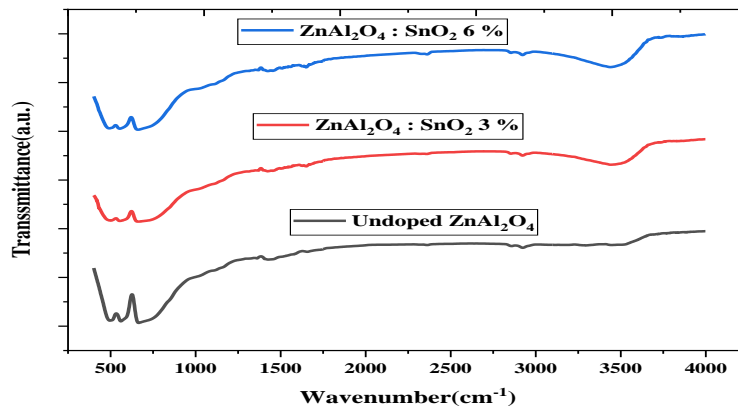


Fig. 2. FTIR spectra of pure and SnO_2 -doped ZnAl_2O_4 thin Films

The bands at 655 cm^{-1} confirm the formation of the normal spinel structure, ZnAl_2O_4 . These spinel peaks at 655 cm^{-1} are consistent with those observed by Abdullah et al. The bands observed in the low-frequency region of the spectrum 487-550 cm^{-1} correspond to the different structures that may form, including zinc oxide and various aluminum oxides [13].

C. UV-Visible spectroscopy:

Fig. 3 shows transmission spectra of the pure ZnAl_2O_4 and SnO_2 doped ZnAl_2O_4 films. The transmission spectra have a general shape characterized by the presence of two distinct regions. We note that the films have a good transparency in the visible 80-95%, which varies slightly with tin oxide doping.

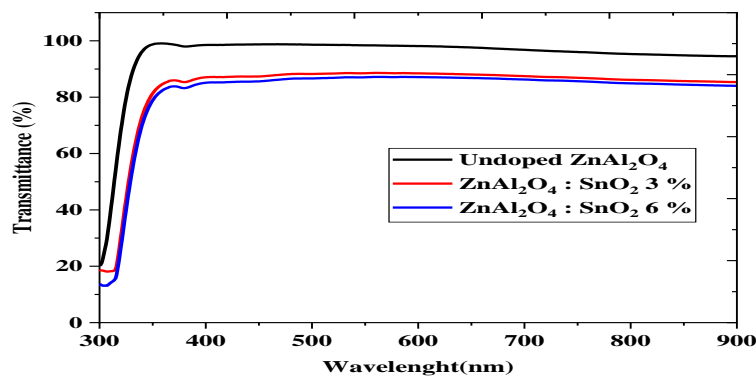


Fig.3. Transmittance spectra of pure and SnO_2 -doped ZnAl_2O_4 films.

By exploiting the Tauc relationship of equation (4), the optical band gap of undoped ZnAl_2O_4 and SnO_2 -doped (3 and 6%) thin films (Table 2) was determined [14].

$$(\alpha h\nu)^{\frac{1}{n}} = A[h\nu - E_g] \dots \dots \dots (2)$$

Where ‘a’ indicates the absorption coefficient, ‘A’ is a constant; ‘h’ corresponds to photon energy and ‘Eg’ stands for the optical band gap of the material. The value of n corresponds to 1/2 and 2 are for direct and indirect band gap transitions respectively.

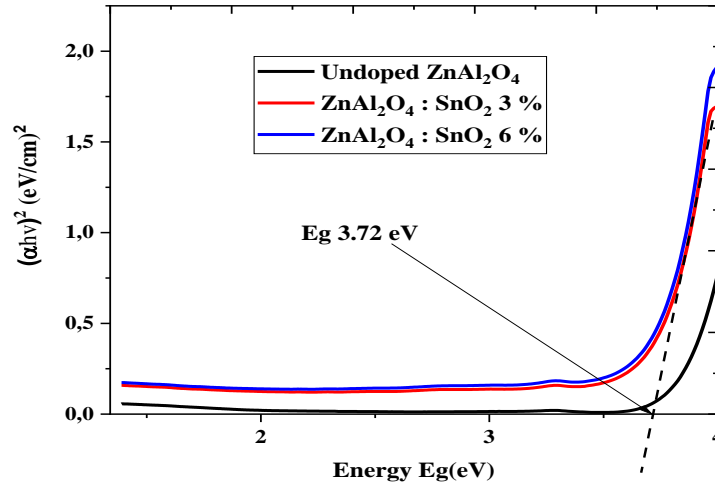


Fig.4. Tauc plot of pure and SnO₂-doped ZnAl₂O₄

Samples	Eg (eV)	Refractive index(n)
Pure ZnAl ₂ O ₄	3.80	2.224
ZnAl ₂ O ₄ : SnO ₂ 3%	3.72	2.236
ZnAl ₂ O ₄ : SnO ₂ 6%	3.68	2.241

Table 2. Band gap values and refractive index of SnO₂ doped and undoped ZnAl₂O₄

Furthermore, the absorption intensity of the doped samples in the ultraviolet region increased significantly, and the absorption edge shifted towards longer wavelengths with increasing SnO₂ concentration [15]. This could be due to the interaction between Sn⁺ ions with the ZnAl₂O₄ matrix, which contributed to the excitation of the generated carriers [16].

D. Complex impedance spectroscopy

Figure 5 is the Nyquist representation of ZnAl₂O₄ thin layers with undoped and SnO₂ doped, where the frequency varies from 75kHz to 1MHz at ambient temperature.

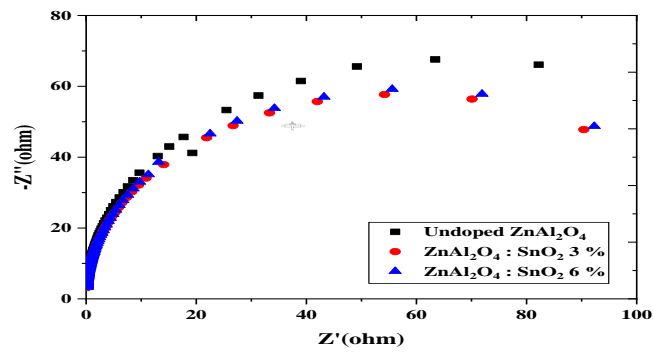


Fig.5 Nyquist plots of pure and SnO₂ doped and undoped ZnAl₂O₄

Samples	$f_{\max}(\text{KHZ})$	$R_p (\Omega)$	C (nF)
Pure ZnAl ₂ O ₄	519.45	67.74	3.06
ZnAl ₂ O ₄ : SnO ₂ 3%	519.44	57.7	5.31
ZnAl ₂ O ₄ : SnO ₂ 6%	519.46	59.2	5.18

Table 3. Values of f_c , R_p and C of undoped and SnO₂-doped ZnAl₂O₄ films

From Table 3 , it can be seen that the resistance R_p decreases while increasing the doping level of SnO₂, reaching a value of 59.2 Ω for a doping level of 6%, while the capacitance increases from 3.06 nF to 5.18 nF for the same doping of 6% in SnO₂.The variation in this capacitance is related to the formation of oxygen vacancies, which is likely due to the substitution of Zn²⁺ by Sn³⁺ or Sn⁴⁺ ions at the grain surfaces [17].

IV. CONCLUSION

In this work, we prepared by the sol-gel process thin films of undoped ZnAl₂O₄ and doped 3%, 6% with SnO₂. The AFM images analysis showed that the surface roughness of the SnO₂ doped ZnAl₂O₄ had rougher surface compared with other samples. The particle size decreases with the increase of SnO₂ content in the prepared samples. FTIR spectra showed the presence of peaks related to bond vibrations in the spinel structure, thus confirming the formation of the materials. The UV-Visible spectroscopy, the transmission rate in the visible range varies from between 90% for thin films 1layer and 95%. The optical band gap was reduced from 3.80 to 3.68 eV upon doping due to the polarization induced by the increase in charge caused by the introduction of impurities. The impedance measurements show that the equivalent circuit of the diagram of ZnAl₂O₄ films is an $R_p C_p$ parallel when the resistance R_p decreases while the capacitance C_p increases with SnO₂ doping. Based on these results, we conclude that SnO₂ doping allows obtaining ZnAl₂O₄ thin films with very interesting structural and optical properties, making these films a good alternative for optoelectronic applications, such as LEDs and lasers.

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